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JUN 2 8 2004

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Dkt. No.: 5545(2616-012)

Gene LEE et al.

Appln. No.: 10/039,333

Group Art Unit: 1765

Filed: November 9, 2001

Examiner: B. Tran

Title: Method for Etching Tungsten

Using NF 3 and Cl 2

OFFICIAL

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R § 1.136

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Applicant hereby petitions for a one (1) month extension of time extending the period for reply to the Office Action mailed February 27, 2004 from May 27, 2004 to June 28, 2004 (June 27, 2004 falling on a Sunday). The Director of the U.S. Patent & Trademark Office is hereby authorized to charge the statutory fee of \$110.00 to Deposit Account No. 18-1579. The Director is also authorized to charge any fee deficiency, or credit any overpayment, to Deposit Account No. 18-1579.

Respectfully Submitted,

ROBERTS ABOKHAIR & MARDULA, LLC

kevin L. PONTIUS Reg. No. 37512 (505) 922-1400

Date: June 28, 2003

Atty. Dkt. No.: 5545 (2616-012)

PAGE 13/13 * RCVD AT 8/28/2004 11:36:57 PM [Eastern Daylight Time] * SVR:USPTO-EFXRF-1/2 * DNIS:8729306 * CSID:505 922 1402 * DURATION (mm-ss):03-42